PROCEEDINGS OF SPIE

Advances in X-Ray/EUV Optics and Components XVI

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1–5 August 2021
San Diego, California, United States

Sponsored and Published by
SPIE

Volume 11837

Proceedings of SPIE 0277-786X, V. 11837

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Author(s), "Title of Paper," in *Advances in X-Ray/EUV Optics and Components XVI*, edited by Christian Morawe, Ali M. Khounsary, Shunji Goto, Proc. of SPIE 11837, Seven-digit Article CID Number (DD/MM/YYYY); (DOI URL).

ISSN: 0277-786X
ISSN: 1996-756X (electronic)

ISBN: 9781510645127
ISBN: 9781510645134 (electronic)

Published by
SPIE
P.O. Box 10, Bellingham, Washington 98227-0010 USA
Telephone +1 360 676 3290 (Pacific Time)
SPIE.org
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